

Hot-pressed silicon nitride ceramics with Lu₂O₃ additives: elastic moduli and fracture toughness

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Abstract

The elastic moduli and fracture toughness of hot-pressed Si₃N₄ ceramics, using 1.68, 3.33, 6.52 and 12.51 wt.% of Lu₂O₃ additives, were studied by means of ultrasonic measurements and Vickers indentation crack size measurements, respectively. The elastic moduli were found to increase with the amount of Lu₂O₃ additive for silicon nitride which was not completely densified. However, the elastic moduli remained nearly constant independent on the amount of additive for completely dense silicon nitride. The elastic moduli of completely dense silicon nitride should reach the following average values: shear modulus $G = 132$ GPa, Young's modulus $E = 338$ GPa, bulk modulus $B = 255$ GPa and Poisson's ratio $\nu = 0.28$. On the other hand, the fracture toughness showed a clear dependence of additive amount for both incompletely and completely dense silicon nitride ceramics. The fracture toughness increased with additive amount over the range 1.68 to 12.51 wt.% Lu₂O₃. The improvement in the fracture toughness with the amount of additive was mainly attributed to elongated grain growth during the sintering process. © 2002 Elsevier Science Ltd. All rights reserved.

Keywords: Elastic moduli; Fracture toughness; Hot-pressing; Lu₂O₃ additive; Si₃N₄

1. Introduction

Silicon nitride (Si₃N₄) ceramics have become an important class of materials for structural applications; because they have excellent high-temperature strength, good resistance to oxidation, high creep resistance, low coefficient of thermal expansion, good resistance to thermal shock and chemical attack.^{1–9} However, it is difficult to sinter pure silicon nitride ceramics due to the low self-diffusivity of this type of covalent material.¹⁰ To improve sinterability oxides such as Y₂O₃, Al₂O₃, MgO, Sc₂O₃, ZrO₂ or Yb₂O₃ are added to pure silicon nitride, providing the formation of a intergranular liquid phase which aids in the densification of the silicon nitride during the sintering process.^{1–9} The mechanical properties, such as elastic moduli, strength, fracture toughness, creep and resistance to oxidation, of the Si₃N₄ ceramics sintered using these additives have been well studied.^{1–9} These studies demonstrate that the degradation

seen in the mechanical properties of Si₃N₄ at elevated temperatures depends strongly on the characteristics of the grain boundary phase, which is determined by the sintering process, additive type and amount. In general, Si₃N₄ containing a secondary grain boundary phase which has a high melting point and is extensively crystallized, has a higher strength at elevated temperature than that of a material containing an amorphous phase with lower viscosity,^{1–4} while larger and elongated grains result in increased fracture toughness by mainly crack bridging.^{5,6} The well-known Si₃N₄ material produced using the Yb₂O₃ additive has been reported to have high and stable mechanical properties up to 1400 °C due to the crystalline Yb₄Si₂O₇N₂ grain boundary phase.^{3,4} However, above 1400 °C it is also found that there is a sharp degradation of these properties. It is clear that higher temperature resistance is desirable and thus further development of Si₃N₄ materials is required.

A new type of Si₃N₄, using Lu₂O₃ as a sintering additive developed recently has unique high-temperature strength and oxidation resistance^{11–13} up to 1500 °C.

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Few studies have reported the strength and oxidation properties of these ceramics at elevated temperatures.^{11–13} Furthermore, the properties such as the elastic moduli and fracture toughness have not been reported. The present paper is focused on the experimental determination of the elastic moduli and fracture toughness of hot-pressed Si₃N₄ ceramics with Lu₂O₃ additives, using ultrasonic testing and the Vickers indentation technique, respectively. Moreover, the effect of the amount of additive on these properties is also discussed.

2. Experimental procedure

2.1. Materials

The starting powders used in the present study were an α -rich Si₃N₄ (SN-E10, UBE Industries, Tokyo, Japan) and Lu₂O₃ (99.9% purity, Shinetsu Chemical Co., Ltd., Tokyo, Japan). The Lu₂O₃ powder was added to the Si₃N₄, and the powder batches were mixed in ethanol for 2 h using a Si₃N₄ ball mill, and then dried in a rotation evaporator. The mixed powder was then preformed into a rectangle, 80 × 45 × 13 mm, in a metal die using cold pressing at 20 MPa. The preforms of the mixture of Si₃N₄ were placed in a carbon die coated with BN powder, and a thin carbon plate was added between these preforms to separate them. Subsequently, these preforms were sintered for 1 h at 1950 °C with a heating rate of 20 °C/min to 1200 °C and then 10 °C/min to 1950 °C under a pressure of 20 MPa in ~1 MPa nitrogen gas environment using a gas-sintering furnace (FVPHR-R-10, FRET-40, Fuji Electric Co., Ltd., Tokyo, Japan). Si₃N₄ ceramics with 1.68, 3.33, 6.52 and 12.51 wt.% Lu₂O₃ additive amounts were fabricated, and their density, ρ , was evaluated by the Archimedes method.

The hot-pressed Si₃N₄ materials were cut, and the resulting surface was polished with a diamond paste up to 0.25 μ m. The surface of the polished specimens was then etched with a CF₄ plasma containing 7.8% O₂. The morphology of the Si₃N₄ microstructure was characterized by scanning electron microscope (SEM). These micrographs were then quantitatively analyzed using an image processing system (LUZEX III, Nireko Co., Ltd., Tokyo, Japan). Minimums of 300 grains in each material were analyzed. The crystalline phase compositions were identified by X-ray diffractometry (XRD).

2.2. Elastic moduli measurement

For the elastic moduli measurements, the hot-pressed Si₃N₄ plates were cut into a rectangle shape specimen with dimensions of ~40 × 4 × 3 mm, and each specimen was ground and polished to obtain parallel opposite faces of better than 3 μ m. Before the measurement, the specimen

thickness, h , was measured using a micrometer with an accuracy of 1 μ m. The elastic moduli of the specimen were determined using ultrasonic equipment (EXPLORER-9000, Matec Instruments, MA, USA) with a fundamental frequency of 15 MHz. The Young's modulus, E , shear modulus, G , bulk modulus, B , and Poisson's ratio, ν , are given by^{14,15}

$$E = \rho V_t^2 \left(\frac{3V_l^2 - 4V_t^2}{V_l^2 - V_t^2} \right), \quad (1a)$$

$$G = \rho V_t^2, \quad (1b)$$

$$B = \frac{EG}{3(3G - E)}, \quad (1c)$$

$$\nu = \frac{E}{2G} - 1, \quad (1d)$$

where ρ is the density, V_l and V_t are the longitudinal and transverse soundwave velocities, respectively, and the V_l and V_t were determined by

$$V_l = \frac{2h}{\Delta t_l}, \quad (2a)$$

$$V_t = \frac{2h}{\Delta t_t}, \quad (2b)$$

where Δt_l and Δt_t are the elapsed times between the pulse and the echo of the longitudinal and transverse waves, respectively. The accuracy of the soundwave velocity measurement was found to be better than 1%.

2.3. Fracture toughness measurement

The fracture toughness, K_{IC} , of the hot-pressed Si₃N₄ was determined using an indentation crack size measurement. The indentation tests were performed on the polished surface of the specimens by loading with a Vickers indenter (AVK-A, Akashi, Co., Ltd., Yokohama, Japan) for 20 s in air at room temperature. The corresponding diagonal of the indentation and crack sizes were measured using an optical microscope attached to the indenter. Three indentation loads of 98, 196 and 294 N were used, and five indents were made at each indentation load.

The fracture toughness, K_{IC} , was calculated using the following relation,¹⁶

$$K_{IC} = 0.016 \left(\frac{E}{H_v} \right)^{1/2} \frac{P}{c^{3/2}}, \quad (3)$$

where E is the Young's modulus (GPa), H_v is the hardness (GPa), P is the indentation load (N) and c is the

crack length (μm). The hardness, H_v , was calculated from,

$$H_v = 1854.4 \frac{P}{d^2}, \quad (4)$$

where d is the diagonal of the indentation (μm).

3. Results and discussion

3.1. Density, microstructure and crystalline phases

Fig. 1 represents several plots of average density and relative density of the hot-pressed Si_3N_4 ceramics against amount of Lu_2O_3 additive. The average density was found to be, $\rho = 3181 \text{ kg/m}^3$ for 1.68 wt.%, $\rho = 3274 \text{ kg/m}^3$ for 3.33 wt.%, $\rho = 3350 \text{ kg/m}^3$ for 6.52 wt.%, and $\rho = 3495 \text{ kg/m}^3$ for 12.51 wt.%. The measured density, ρ , increases with the increase in amount of Lu_2O_3 additive, and the increase rate correlates to amount of Lu_2O_3 additive; the increase rate at lower amount of Lu_2O_3 additive (≤ 3.33 wt.%) is larger than one at higher amount of Lu_2O_3 additive (> 3.33 wt.%). The increase in the density of Si_3N_4 with amount of Lu_2O_3 additive should be attributed to the formation of an intergranular amorphous phase.¹⁷ The relative density is defined as ρ/ρ_t where ρ_t is the theoretical density of the mixture of Si_3N_4 and is calculated using the role of mixture. The theoretical density of pure Si_3N_4 was taken as 3190 kg/m^3 and that of pure Lu_2O_3 as 9410 kg/m^3 . The relative density reveals a different dependence of Lu_2O_3 amount against the density. The relative density increases with the amount of additive used from 1.68 to 3.33 wt.%. For amounts higher than 3.33 wt.% it is independent on amount of Lu_2O_3 additive and approximately equal to unit, this means that at least 3.33 wt.% Lu_2O_3 is needed to obtain completely dense Si_3N_4 from the sintering process.

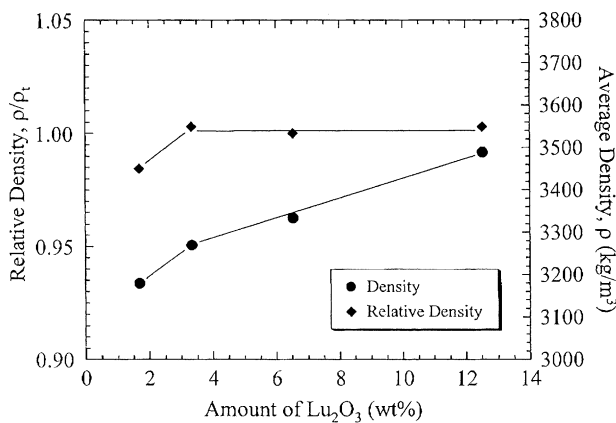


Fig. 1. Relative density and average density of the hot-pressed Si_3N_4 ceramics against amount of Lu_2O_3 additives.

Fig. 2 shows SEM micrographs of microstructures for the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives. The histograms of grain-section diameter are also shown. In these micrographs, the $\beta\text{-Si}_3\text{N}_4$ grains are seen in dark contrast, while the grain boundary phase appears in light contrast. The material microstructure can be described with respect to the additive content as follows: for 1.68 wt.% Lu_2O_3 -containing Si_3N_4 material there are a few elongated grains in a fine grains microstructure [Fig. 2(a)]; with further increase in amount of additive, the grains become coarser [Fig. 2(b)], especially the amount of the elongated grains significantly increases as the amount of additive is equal to or greater than 6.52 wt.% [Fig. 2(c) and (d)]. In addition, a broad grain diameter size distribution is observed for the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives [Fig. 2(e)–(g)], with exception of the 12.51 wt.% composition ceramic exhibits a bimodal grain diameter size distribution although this bimodal distribution is not very noticeable [Fig. 2(h)]. A change of the grain-section diameter with amount of additive is shown in Fig. 3. This shows that an increase of the additive accelerates grain growth and coarsening. On the other hand, a thin grain boundary phase, with net-like shape, is observed in the hot-pressed Si_3N_4 ceramics with 1.68 and 3.33 wt.% Lu_2O_3 additives [Fig. 2(a) and (b)]. However, the grain boundary phase becomes thicker and the net-like structure becomes small and/or partially disappearance as the amount of additive is greater 3.33 wt.% (Fig. 2(c) and (d)). X-ray diffraction patterns show that the grain boundary phase consists of crystalline $\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$ phase for all compositions Si_3N_4 materials (Table 1), trace amount of crystalline Lu_2SiO_5 phase is also present for the 12.51 wt.% Lu_2O_3 -containing Si_3N_4 , however. Electron microscopy study¹⁸ confirmed very recently a completely crystalline $\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$ secondary phase for the hot-pressed Si_3N_4 with a lower amount of Lu_2O_3 additive, e.g. 3.33 wt.% Lu_2O_3 composition ceramic, and for the Si_3N_4 with a higher amount of Lu_2O_3 additive approximately half of the triple-grains junctions pockets were devitrification, e.g. 12.51 wt.% Lu_2O_3 composition case.

3.2. Elastic moduli

Fig. 4 shows the measured elastic moduli of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives. The measured average shear modulus, G , Young's modulus, E , bulk modulus, B , and Poisson's ratio, ν , are given as follows: $G = 124.8$, $E = 319.7$ and $B = 243.0$ GPa and $\nu = 0.281$ for 1.68 wt.%, $G = 132.4$, $E = 338.0$ and $B = 251.3$ GPa and $\nu = 0.276$ for 3.33 wt.%, $G = 132.2$, $E = 338.1$ and $B = 254.5$ GPa and $\nu = 0.279$ for 6.52 wt.%, and $G = 132.6$, $E = 340.0$ and $B = 260.0$ GPa and $\nu = 0.282$ for 12.51 wt.%. The elastic moduli obtained for completely dense silicon nitride are slightly higher

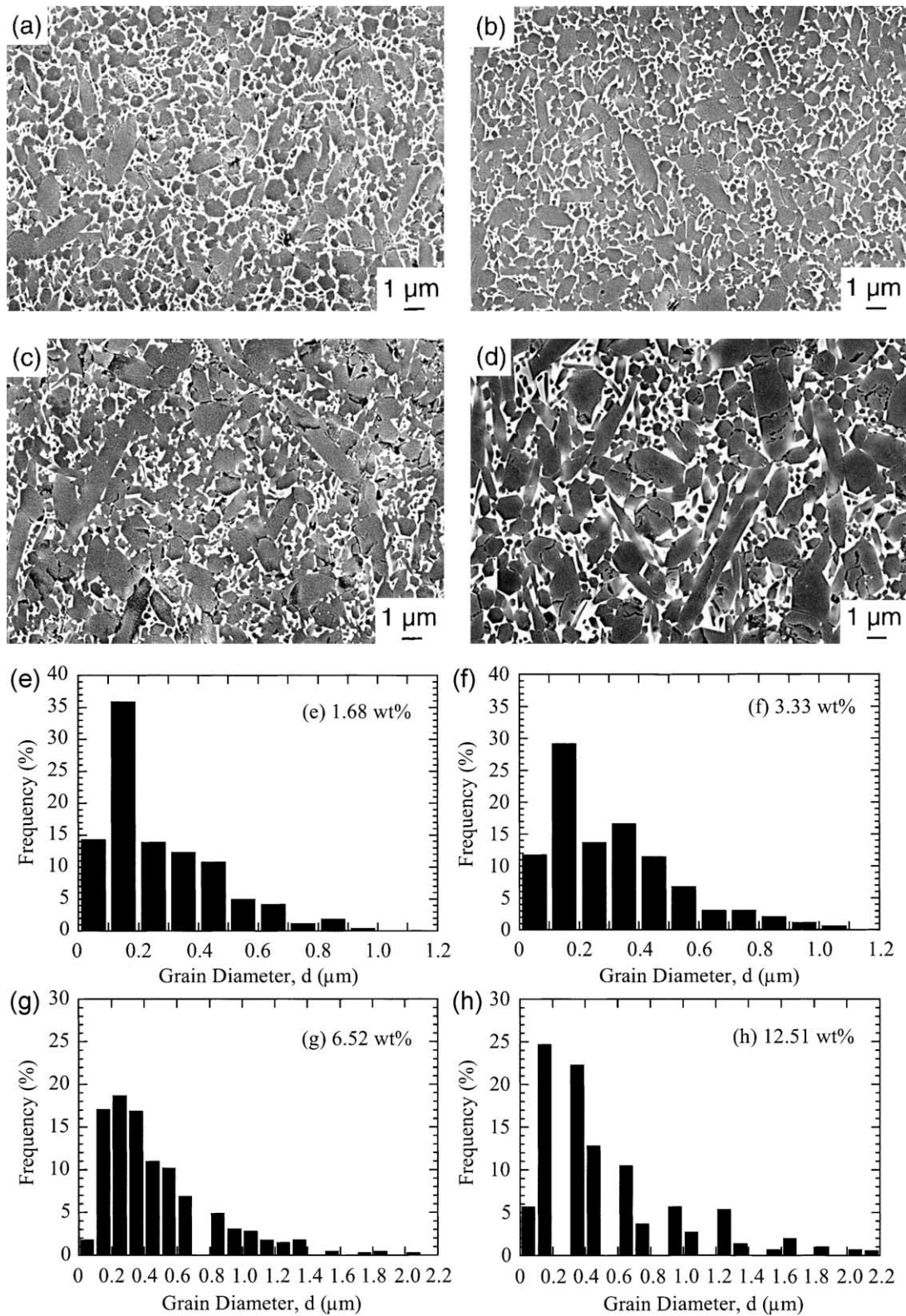


Fig. 2. SEM micrographs of microstructures of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives of (a) 1.68, (b) 3.33, (c) 6.52 and (d) 12.51 wt.%. The corresponding histograms of the grain-section diameter are given in (e), (f), (g) and (h), respectively.

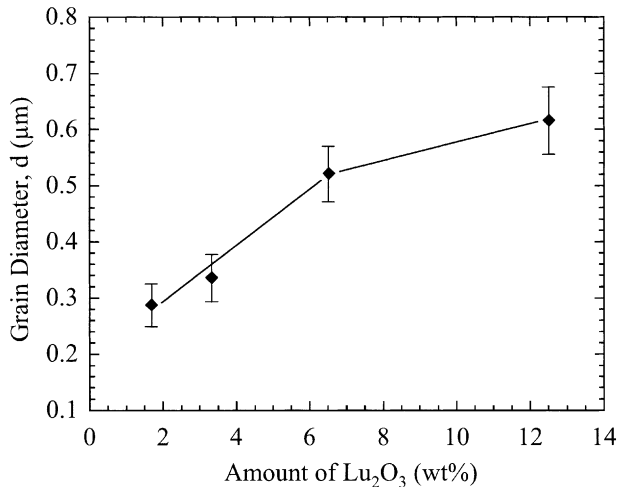


Fig. 3. Average grain diameter of the hot-pressed Si_3N_4 ceramics versus amount of Lu_2O_3 additives.

than those of Si_3N_4 with other additives, reported elsewhere.^{3,5,17} In addition, the shear modulus, Young's modulus and bulk modulus are found to increase with the amount of Lu_2O_3 additive for the Si_3N_4 which is not completely densified ($\rho/\rho_t = 0.985$ for 1.68 wt.% Lu_2O_3 composition ceramic). However, both the shear modulus and Young's modulus remain nearly constant and the bulk modulus increases slightly with a further increase in the amount of additive for the completely

Table 1

Crystalline phases present in the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives

Amount of Lu_2O_3 (wt.%)	Primary phase	Secondary phase	Minor phase
1.68	$\beta\text{-Si}_3\text{N}_4$	$\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$	
3.33	$\beta\text{-Si}_3\text{N}_4$	$\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$	
6.52	$\beta\text{-Si}_3\text{N}_4$	$\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$	
12.51	$\beta\text{-Si}_3\text{N}_4$	$\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$	Lu_2SiO_5

dense Si_3N_4 ($\rho/\rho_t = 1.0$ for ≥ 3.33 wt.% Lu_2O_3 composition ceramics). This finding indicated that the pore volume is a main factor that affects the elastic moduli of the Si_3N_4 materials. The bulk modulus increases slightly with increase in the amount of additive; this is probably attributed to an increase in the amount of the grain boundary phases, and the change of their compositions and residual stresses caused by crystallization of these phases during the sintering process. This is the case, because the bulk modulus has a greater sensitive in a change of these factors than both the shear and Young's moduli.¹⁵ However, Poisson's ratio is nearly constant for either incompletely or completely dense Si_3N_4 , as well as is independent on the amount of additive in the range of the present test, showing that this parameter is insensitive to the pore fraction for the Si_3N_4 specimen sintered with a high-density (relative density $> 98\%$).

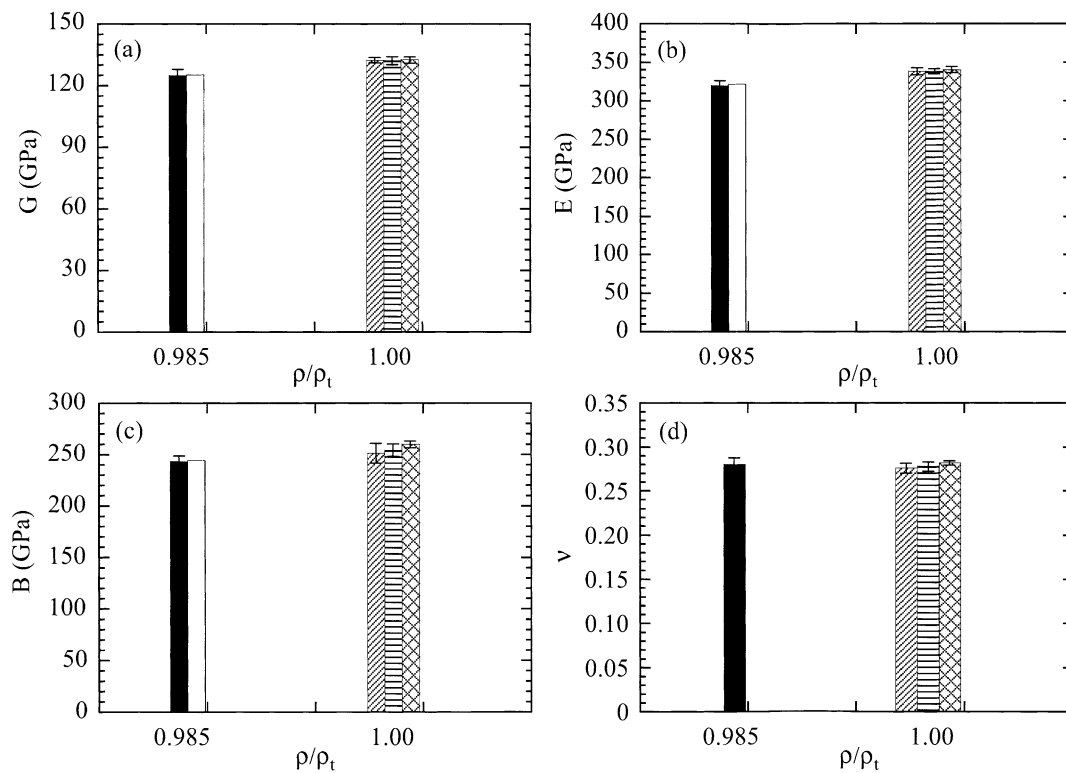


Fig. 4. Elastic moduli of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives against relative density, (a) shear modulus, (b) Young's modulus, (c) bulk modulus and (d) Poisson's ratio (■ 1.68 wt.%, ▨ 3.33 wt.%, ▤ 6.52 wt.%, ▩ 12.51 wt.%, □ Predicted for 1.68 wt.%).

Assuming that the effect of pore structure on elastic moduli is neglected, the elastic moduli can be given as¹⁴

$$M = M_0(1 - \eta V_p) \quad (5)$$

where M and M_0 are the elastic moduli (G , E and B) at volume fraction porosity, V_p ($= 1 - \rho/\rho_t$), and zero, respectively, and η is a constant for each elastic modulus. The calculated maximum values of the completely dense Si_3N_4 are defined as G_0 , E_0 and B_0 , and $G_0 = 132.6$, $E_0 = 340.0$ and $B_0 = 260.0$ GPa. Assuming that η is independent of additive kinds, it is 3.62 for G , 3.47 for E and 3.95 for B according to reported data in Ref. ¹⁷ for the present Si_3N_4 materials. The predicted elastic moduli for the hot-pressed 1.68 wt.% Lu_2O_3 -containing Si_3N_4 ceramic are given in Fig. 4 by the dotted column. This is consistent with the measured elastic moduli values for the Si_3N_4 with 1.68 wt.% Lu_2O_3 that contains 1.5% porosity.

Fig. 5 shows a change of the measured soundwave velocity with amount of additive for the hot-pressed Si_3N_4 ceramics. The average soundwave velocities are as follows: $V_l = 11345$ and $V_t = 6264$ m/s for 1.68 wt.%, $V_l = 11431$ and $V_t = 6359$ m/s for 3.33 wt.%, $V_l = 11339$

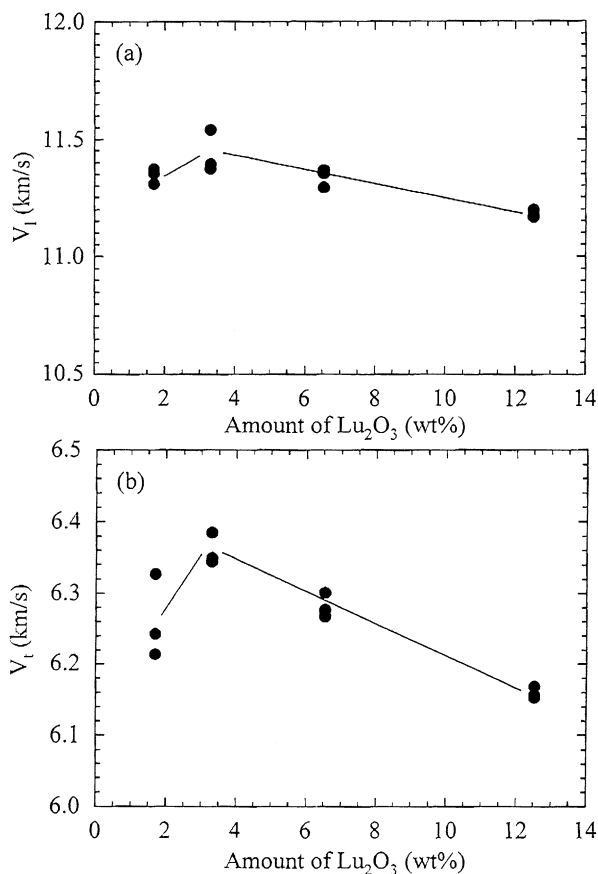


Fig. 5. Change of measured longitudinal soundwave velocity (a) and transverse soundwave velocity (b) with amount of Lu_2O_3 additives for the hot-pressed Si_3N_4 ceramics.

and $V_t = 6282$ m/s for 6.52 wt.%, $V_l = 11179$ and $V_t = 6160$ m/s for 12.51 wt.%. Differing with the elastic moduli, the soundwave velocity depends on amount of additive in Si_3N_4 , although this dependence is weak. Both the longitudinal and transverse soundwave velocities increase initially as the amount of additive begins to increase, the soundwave velocities achieve a maximum value at 3.33 wt.% Lu_2O_3 , and then they decrease slowly with the continuous increase in the amount of additive. This seems to attribute to an increase in the amount of the grain boundary phase and its composition change, because the thicker intergraular phase layer and complex phases between grains hinder the transmission of soundwaves.

The measured density, soundwave velocity and elastic moduli of the hot-pressed Si_3N_4 ceramics with various amounts of the Lu_2O_3 additive are summarized in Table 2.

3.3. Fracture toughening

The hardness and fracture toughness of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives determined by indentation crack size measurements are plotted against the amount of additive in Fig. 6. The hardness of the Si_3N_4 , H_v , shows a slight increase from 1.68 wt.% to 3.33 wt.% of Lu_2O_3 , then a slow decrease is observed as the amount of additive is increased further. The hardness for 12.51 wt.% Lu_2O_3 -containing Si_3N_4 ceramic is nearly equal to that of 1.68 Lu_2O_3 -containing Si_3N_4 ceramic, showing a slight dependence on amount of additive. Conversely, the fracture toughness, K_{IC} , shows a clear dependence of additive amount and increases with an increase in amount of additive; the rate of increase from 1.68 to 6.52 wt.% of Lu_2O_3 is greater than that from 6.52 wt.% to 12.51 wt.% of Lu_2O_3 . Note that

Table 2
Measured densities, soundwave velocities and elastic moduli of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives

Amount of Lu_2O_3 (wt.%)	Density ρ (kg/m^3)	Soundwave velocity (m/s)		Elastic moduli			
		V_l	V_t	G (GPa)	E (GPa)	B (GPa)	ν
1.68	3182	11,309	6243	124.1	317.8	241.6	0.281
	3180	11,354	6334	127.6	325.1	239.8	0.274
	3180	11,373	6214	122.8	316.1	247.6	0.287
3.33	3261	11,542	6385	133.0	340.3	257.2	0.280
	3282	11,374	6345	132.2	336.8	248.4	0.274
	3279	11,377	6347	132.1	336.6	248.3	0.274
6.52	3353	11,294	6301	133.1	339.2	250.2	0.274
	3352	11,354	6268	131.7	337.4	256.5	0.281
	3345	11,369	6277	131.8	337.6	256.7	0.281
12.51	3491	11,166	6153	132.2	338.9	259.1	0.282
	3492	11,174	6157	132.4	339.4	259.5	0.282
	3503	11,196	6169	133.3	341.8	261.3	0.282

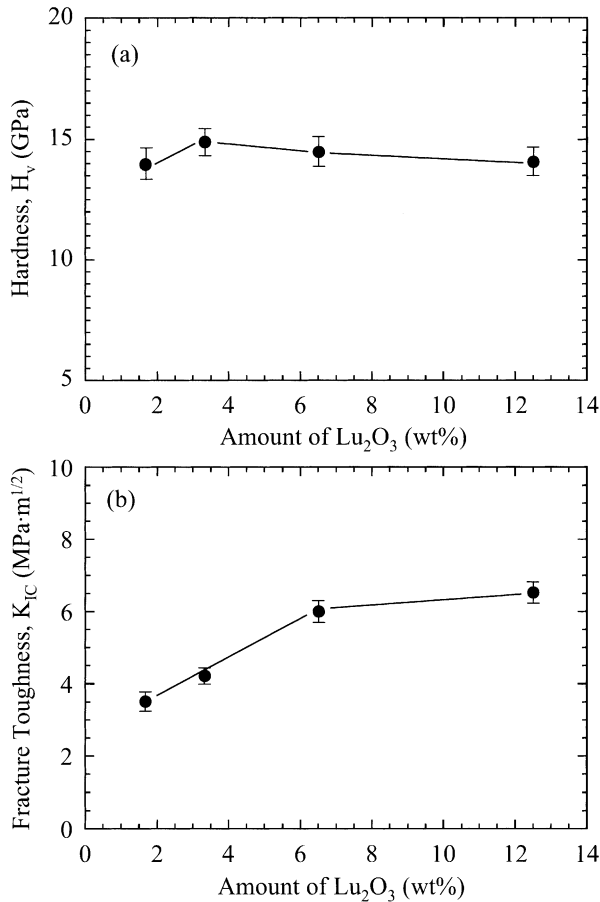


Fig. 6. (a) Hardness and (b) fracture toughness of the hot-pressed Si₃N₄ ceramics versus amount of Lu₂O₃ additives.

the evaluated hardness and fracture toughness tend to decrease with increasing indentation load (Table 3). The average hardness over all the indentation loads used was $H_v = 13.89$ GPa for 1.68 wt.% Lu₂O₃, $H_v = 14.90$ GPa for 3.33 wt.% Lu₂O₃, $H_v = 14.48$ GPa for 6.52 wt.% Lu₂O₃, $H_v = 14.08$ GPa for 12.51 wt.% Lu₂O₃. The corresponding average fracture toughness is $K_{IC} = 3.46$ MPa m^{1/2} for 1.68 wt.% Lu₂O₃, $K_{IC} = 4.22$ MPa m^{1/2} for 3.33 wt.% Lu₂O₃, $K_{IC} = 6.00$ MPa m^{1/2} for 6.52 wt.% Lu₂O₃, $K_{IC} = 6.53$ MPa m^{1/2} for 12.51 wt.% Lu₂O₃. These values are nearly the same as those reported on the hot-pressed Si₃N₄ ceramics with Yb₂O₃ and Y₂O₃ additives^{3,4,15} except for the measured value at 1.68 wt.%, which is lower due to incomplete densification.

Table 3
Vickers indentation results of hot-pressed Si₃N₄ ceramics with Lu₂O₃ additives

Amount of Lu ₂ O ₃ (wt.%)	Load P (N)	Diagonal $2a$ (μm)	Crack length c (μm)	Hardness H_v (GPa)	Fracture toughness K_{IC} (MPa m ^{1/2})
1.68	98	113.8±2.4	160.0±5.3	14.25±0.62	3.51±0.21
	196	161.4±3.3	264.8±15.3	13.97±0.58	3.48±0.25
	294	201.4±5.3	358.2±6.8	13.46±0.69	3.38±0.16
3.33	98	110.4±1.5	143.6±3.8	14.92±0.41	4.34±0.13
	196	156.6±2.6	236.4±5.6	14.83±0.49	4.12±0.14
	294	191.0±2.2	305.0±7.0	14.95±0.35	4.20±0.10
6.52	98	111.2±3.3	115.4±2.1	14.73±0.86	6.16±0.31
	196	159.6±2.7	189.2±5.0	14.28±0.49	5.82±0.27
	294	194.4±2.1	243.4±8.1	14.43±0.31	6.02±0.32
12.51	98	113.6±2.7	109.2±1.9	14.10±0.65	6.72±0.28
	196	160.0±2.7	177.8±5.3	14.21±0.48	6.48±0.28
	294	197.8±2.4	236.2±7.1	13.94±0.34	6.40±0.24

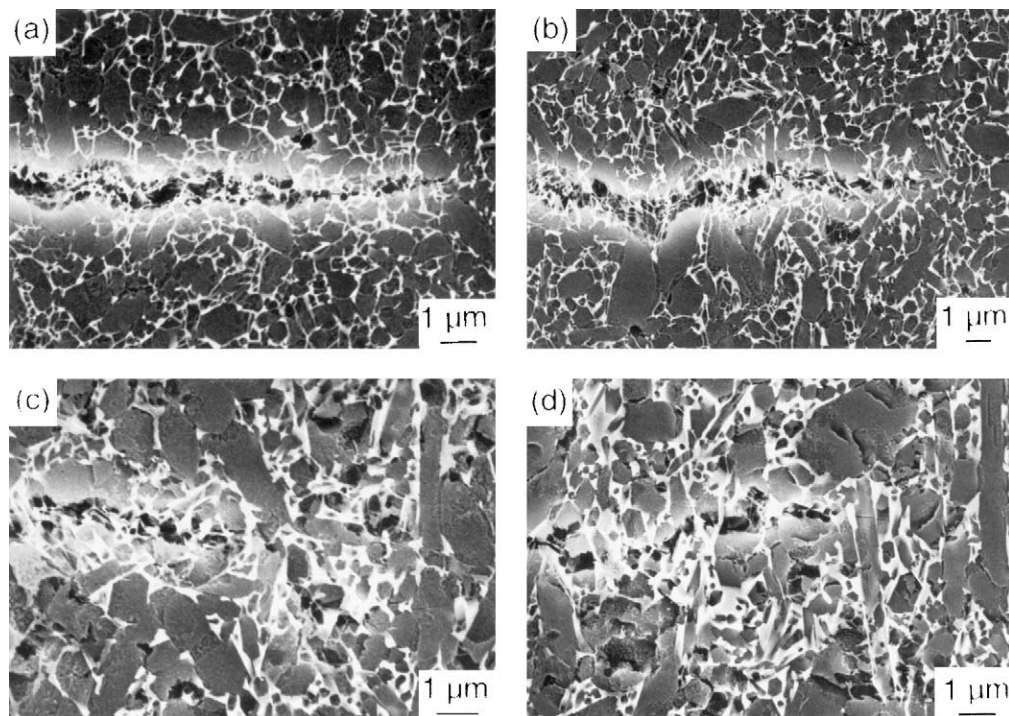


Fig. 7. Crack propagation behavior of the hot-pressed Si₃N₄ ceramics with Lu₂O₃ additives of (a) 1.68, (b) 3.33, (c) 6.52 and (d) 12.51 wt.%.

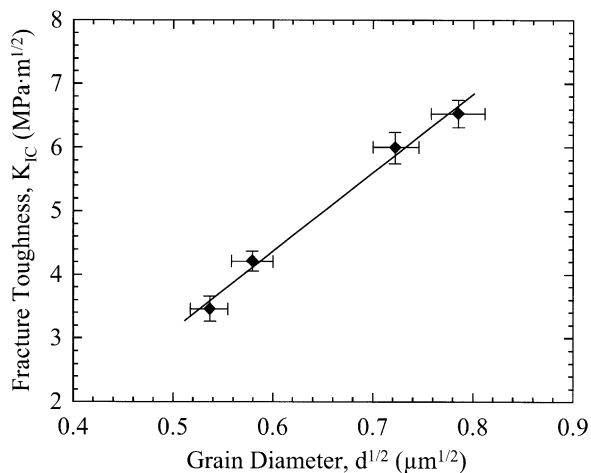


Fig. 8. Fracture toughness of the hot-pressed Si_3N_4 ceramics with Lu_2O_3 additives versus grain-section diameter, showing a dominated effect of grain diameter on fracture toughness.

The crack propagation behavior was studied using SEM imaging on Vickers indentation cracks in several plasma-etched samples, as shown in Fig. 7. In the Si_3N_4 with 1.68 wt.% Lu_2O_3 , the predominantly intergranular crack path is observed and there is little interaction between the crack and grains [Fig. 7(a)]. In addition, the thinner grain boundary phase, with a net-like shape, still remains connected, acting as elastic bridging over the crack faces. This phenomenon differs from Si_3N_4 with other kinds of additives and no similar behavior was seen.^{4,6} This crack propagation characterization remains up to 3.33 wt.% Lu_2O_3 exception the grain boundary phase amount increases [Fig. 7(b)]. When the amount of additive increases to 6.52 wt.%, the crack tends to be deflected around larger grains [Fig. 7(c)], it is also seen to cut elongated grains. This suggests that it is energetically favorable for the crack to cut elongated grains, rather than be deflected by them or pull them out. Furthermore, a thicker and scattered grain boundary phase is observed instead of the thinner grain boundary phase. This indicated that an extensive interaction between the crack and the grains occurred, meaning the higher fracture toughness in the Si_3N_4 with 6.52 wt.% Lu_2O_3 than that in <6.52 wt.% Lu_2O_3 . With further addition of Lu_2O_3 , no noticeable change in the crack propagation behavior is observed exception for an increase in grain boundary phase amount [Fig. 7(d)].

The fracture toughness depends on the grain size, shape, volume fraction of the bridging grains, and frictional sliding stress between the grains.^{4–6} A dependence of fracture toughness of Si_3N_4 on grain-section diameter is shown in Fig. 8. An approximately linear relationship is seen between the fracture toughness and grain-section diameter, that is the bigger is the grain diameter and the higher is the fracture toughness. This suggests that the fracture toughness of Si_3N_4 is mainly dominated by the

grain diameter; especially the elongated grains are effective for increasing fracture toughness.

4. Conclusions

Silicon nitride ceramic with various amounts of Lu_2O_3 additive was produced using the hot-pressing process. The elastic moduli were determined by means of ultrasonic measurements, and the fracture toughness was measured using Vickers indentation. The observed elastic moduli were higher than those of silicon nitride using other additives, and the measured fracture toughness was found to be comparable to that of these other materials. From these results, the following conclusions may be drawn:

1. The densification of silicon nitride by hot-press sintering was dependent on the amount of Lu_2O_3 additive and approximately 3.33 wt.% Lu_2O_3 was needed to densify Si_3N_4 completely at 1950 °C under a pressure of 20 MPa.
2. The hot-pressed silicon nitride with 1.68 wt.% Lu_2O_3 consisted of $\beta\text{-Si}_3\text{N}_4$ matrix with $\text{Lu}_4\text{Si}_2\text{O}_7\text{N}_2$ grain boundary phase, and this composition remained up to 6.52 wt.% Lu_2O_3 , where as a new Lu_2SiO_5 phase was identified in the silicon nitride with 12.51 wt.% Lu_2O_3 . The $\beta\text{-Si}_3\text{N}_4$ grain-section diameter was observed to increase with increasing amount of additive, and this increase was clearly noticeable as the amount of additive was equal to or greater than 6.52 wt.%.
3. The elastic moduli of the hot-pressed silicon nitride increased with an increase in amount of additive for incompletely dense material. However, the shear modulus and Young's modulus remained nearly constant independent of additive amount, and the bulk modulus slightly increased with amount of additive for completely dense material. The average values of the elastic moduli for completely dense Si_3N_4 were found to be: $G = 132$ GPa, $E = 338$ GPa, $B = 255$ GPa and $\nu = 0.28$.
4. The fracture toughness of the hot-pressed silicon nitride was found to increase rapidly with the amount of Lu_2O_3 up to 6.52 wt.%, and then to increase slowly. The grain-section diameter dominated the fracture toughness.

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